Control of Impurity Phase Segregation in a PdCrO₂/CuCrO₂ Heterostructure*

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PdCrO₂ films are synthesized on CuCrO₂ buffer layers on Al₂O₃ substrates. This synthesis is accompanied by impurity phase segregation, which hampers the synthesis of high quality PdCrO₂ films. The potential causes of impurity phase segregation were studied by using a combination of experiments and ab initio calculations. X-ray diffraction and scanning transmission electron microscopy experiments revealed impurity phases of Cu_xPd_{1-x} alloy and chromium oxides, Cr_2O_3 and Cr_3O_4 , in PdCrO₂. Calculations determined that oxygen deficiency can cause the impurity phase segregation. Therefore, preventing oxygen release from delafossites could suppress the impurity phase segregation. The amounts of Cr_2O_3 and Cr_3O_4 depend differently on temperature and oxygen partial pressure. A reasonable theory-based explanation for this experimental observation is provided.

I. INTRODUCTION

Delafossites are intriguing materials that can combine 2D electronic conductivity in the cation A layers and magnetism in slightly distorted octahedra in the BO_6 layers, which stack alternately [1–3]. The abundant possible choices of monovalent A and trivalent B cations lead to a number of delafossite materials with diverse physical properties [4, 5]. The ABO₂ delafossites were first reported in 1971 by a group of the DuPont Experimental Station [1-4]. A quarter of century after delafossites were first reported, they received renewed attention when the transparent *p*-type semiconductor $CuAlO_2$ was discovered [6, 7]. Simultaneously, Tanaka et al.[8] reported the strong anisotropy of electronic conduction for the metallic PdCoO₂ single crystals [3]. One decade later, Takatsu and Maeno et al., working on PdCoO₂ and PdCrO₂, reported the growth of single crystals of PdCrO₂ [9]. These single crystals exhibit intriguing phenomena^[4] such as the unconventional anomalous Hall effect in PdCrO₂[10] and anomalous temperature dependence of specific heat and electrical resistivity that are driven by high-frequency phonons in PdCoO₂[10]. Their seminal work originated the continuous study of delafossite metals to this day.

Delafossite metals have electronic conductivity comparable with the most conductive pure metals [3, 4, 8, 11] owing to their remarkably long electronic mean free paths of up to 20 μ m [4, 12, 13]. Among delafossite metals, PdCrO₂ is especially interesting because it coexists with a layerwise non-collinear spin state [14–18] and exhibits high electronic conductivity [16]. Its topological properties, primarily

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caused by spin–orbit coupling in Pd, allow for the observation of an unconventional anomalous Hall effect [10, 19] in bulk PdCrO₂. Additionally, PdCrO₂ films and surfaces have been studied. Angle-resolved photoemission spectroscopy experiments showed that Pd-terminated PdCrO₂ has surface ferromagnetism, which may originate from the Stoner-like instability[20, 21]. Experimental studies of PdCrO₂ films established that the antiferromagnetic spin state remains stable down to a thickness of 3.6 nm [22].

Hybrid layered heterostructures, composed of PdCrO₂ and other delafossite materials, could exhibit interesting and different phenomena than their parent compounds [23]. However, despite the interest in the material, the epitaxial growth of PdCrO₂ films has not been widely studied [22, 24–27]. The growth of PdCrO₂ films on Al₂O₃ is sometimes accompanied by impurity phases (i.e., Cu_xPd_{1-x} alloy and chromium oxides) [22]. Recent research discovered that a one-monolayer buffer layer of CuCrO₂ on an Al₂O₃ substrate suppresses this instability [22]. However, a nonnegligible amount of impurity phase is still formed. Understanding the mechanism of the impurity phase segregation and how to suppress it is highly desired for the growth of heterostructures containing PdCrO₂ or other Pd-based delafossites.

In this work, the mechanism of impurity phase segregation of a heterostructure of a PdCrO₂ layer with a CuCrO₂ buffer layer on an Al₂O₃ substrate was studied using a combination of experiments and ab initio calculations. X-ray diffraction (XRD) and scanning transmission electron microscopy (STEM) experiments were performed, and the segregation of Cu_xPd_{1-x} alloy and chromium oxide (Cr_2O_3 and Cr_3O_4) impurity phases was observed. These experiments revealed that the formation of Cr₂O₃ negatively correlates with oxygen partial pressure, whereas the formation of Cr_3O_4 does not correlate with oxygen partial pressure. Moreover, the Cr_2O_3 (Cr_3O_4) formation weakly (strongly) positively correlates with temperature. The segregation of Cu_rPd_{1-r} alloy and chromium oxide impurity phases must be accompanied by the appearance or disappearance of point defects because the segregation processes are not stoichiometric. In this scenario, calculations revealed that oxygen vacancies can cause the impurity phase segregation. Calculations also revealed that the

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segregation of Cr_2O_3 or Cr_3O_4 is energetically the most favorable among the chromium oxides, agreeing with the experiments described in Section III A. Finally, the calculations also revealed that the formation of Cr_2O_3 and Cr_3O_4 depends on temperature and oxygen partial pressure.

II. EXPERIMENTAL AND CALCULATION DETAILS

A. Experimental details

A PdCrO₂ layer with thickness of approximately 10 nm was grown on a one-monolayer (~0.38 nm) CuCrO₂ buffer layer on an Al₂O₃ substrate via pulsed laser deposition using polycrystalline targets. Before the film growth, commercially available Al₂O₃ (0001) substrates (CrysTec, Germany) were annealed at 1100 °C for 1 h to achieve atomically flat surfaces with step-terrace structure. For PdCrO₂ films, the growth conditions were widely varied: temperature (T) was 500–800 $^{\circ}$ C, and oxygen partial pressure (P_{O_2}) was 10–500 mTorr. The repetition rate and fluence of KrF excimer laser ($\lambda = 248$ nm) were fixed at 5 Hz and 1.5 J/cm², respectively. The crosssectional STEM specimens were prepared using low-energy ion milling at LN₂ temperature after mechanical polishing. High-angle annular dark field (HAADF) STEM measurements were performed on a Nion UltraSTEM200 operated at 200 kV. The microscope is equipped with a cold-field emission gun and a third- and fifth-order aberration corrector for sub-angstrom resolution. The convergence half-angle of 30 mrad was used, and the inner angle of the HAADF STEM was approximately 65 mrad.

B. Calculation details

Density functional theory (DFT) implemented in the VASP package [28] was used to understand the energetics of competing phases during the experimental growth process. The Perdew–Burke–Ernzerhof (PBE)+U method [29, 30] was used. The Hubbard U correction was applied to the 3d shell of the Cr atoms. The U value was 3.3 eV, which was optimized compared with the results of the HSE06 functional [31], as described in the Supporting Information. The core electrons were replaced with pseudopotentials made by the projector-augmented wave method accompanied by the VASP code [32-34]. The cutoff energy was 520 eV, and k-spacing was 0.30 Å⁻¹, which converged the Cr vacancy formation energy in CuCrO₂ within 2 meV. Experimental lattice vectors for CuCrO₂ [35], PdCrO₂ [36], and Al₂O₃ were used [37]. The lattice vectors reported in the Materials project [38] were used for chromium oxides and chromium metal [39]. The atomic coordinates were relaxed for the functional. The convergence criteria for the self-consistent field and ionic cycles were 1.0×10^{-7} eV and 1.0×10^{-6} eV, respectively.

III. RESULTS AND DISCUSSIONS

A. Segregation of impurity phases

Impurity phases including $Cu_{x}Pd_{1-x}$, $Cr_{2}O_{3}$, and $Cr_{3}O_{4}$ have been observed experimentally [40]. In Figure 1 we show in addition to 2θ – θ XRD spectrum, the intensity of the XRD data as a function of the growth conditions. As reported in Ref. [22], the high-quality PdCrO₂ films can be achieved only within a relatively narrow growth window. Outside the growth window, the metallic properties are severely deteriorated by the impurity formation. The resistance could not be measured because of the high resistivity. The rectangular boxes in Figure 1 highlight the main impurities observed in XRD: Cr₃O₄ and Cr₂O₃. The bottom two panels of Figure 1 map the XRD intensities of Cr₃O₄ and Cr₂O₃ for temperature and oxygen partial pressure. The relative abundances between Cr₃O₄ and Cr₂O₃ are difficult to assess quantitatively using the XRD intensities because the XRD reflectivity varies with substances and angles. However, we use the intensities to assess qualitatively how the formation of each substance is affected by growth conditions. The XRD intensity of Cr₃O₄ strongly positively correlates with temperature (correlation coefficient [41] $\rho = +0.82$), whereas the correlation between the XRD intensity of Cr_2O_3 and temperature is weak ($\rho = +0.19$). Moreover, Cr_3O_4 's peak strength does not depend on oxygen partial pressure ($\rho = +0.01$), but Cr₂O₃'s peak strength negatively depends on oxygen partial pressure ($\rho = -0.48$). These results are compared with our calculations in the last paragraph of Section III F.

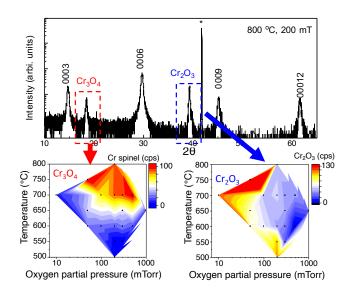


FIG. 1. XRD spectrum and mapping of XRD peak strengths of Cr_3O_4 and Cr_2O_3 for temperature and oxygen partial pressure. This measurement was performed for an approximately 6 nm PdCrO₂ film grown on a one-monolayer CuCrO₂ buffer layer.

B. Point-defect formation energy

Because the system segregates oxygen-deficient oxides Cr_2O_3 or Cr_3O_4 , the segregation process should be accompanied by the appearance or disappearance of point defects. The ratio of O to Cr (O/Cr) in Cr_2O_3 is O/Cr = 1.5. In Cr_3O_4 , O/Cr is about 1.3. In the delafossite materials, O/Cr is 2.0. Therefore, the formation energies of multiple types of point self-defects in bulk Al_2O_3 , CuCrO₂, and PdCrO₂ were calculated. To simplify the problem, defects in the bulk were calculated, even though samples with different thickness of PdCrO₂ and CuCrO₂ films have been grown in this and other works [22, 40].

The following describes the notation used for the point defects and explains how to evaluate the formation energies. V_{Cr} , V_{Cu} , V_{Pd} , and V_0 indicate vacancies in the Cr, Cu, Pd, and O sites. The Cu (Pd) replacement defects in the Cr sites, or *antisite defects*, are indicated by Cu_{Cr} (Pd_{Cr}). Larger defect complexes such as Cu_{Cr}&V_{Cu} (Pd_{Cr}&V_{Pd}) can form when Cu (Pd) atoms move to a preformed V_{Cr} , leaving the $V_{Cr(Pd)}$. The formation energies of these defects are given as follows: for CuCrO₂,

$$\Delta E (V_{\alpha}) = E (CuCrO_{2})_{V_{\alpha}} - E (CuCrO_{2})_{bulk} + \mu_{\alpha}, \quad (\alpha = Cu, Cr, or O), \quad (1)$$
$$\Delta E (Cu_{Cr} \& V_{Cu}) = E (CuCrO_{2})_{Cu_{Cr} \& V_{Cu}} - E (CuCrO_{2})_{bulk} + \mu_{Cr}, \quad (2)$$

and for PdCrO₂,

$$\Delta E (V_{\alpha}) = E (PdCrO_2)_{V_{\alpha}} - E (PdCrO_2)_{bulk} + \mu_{\alpha}, \quad (\alpha = Pd, Cr \text{ or } O), \qquad (3)$$
$$\Delta E (Pd_{Cr} \& V_{Pd}) = E (PdCrO_2)_{Pd_{Cr} \& V_{Pd}} - E (PdCrO_2)_{bulk} + \mu_{Cr}. \qquad (4)$$

Here, $E(\text{CuCrO}_2)_{\text{bulk}}$ and $E(\text{PdCrO}_2)_{\text{bulk}}$ are the total energies of pristine delafossite structures. $E(\text{CuCrO}_2)_X$ and $E(\text{PdCrO}_2)_X$ are the total energies of structures with type-*X* defects. The chemical potential of atomic species α is μ_{α} . The oxygen vacancy formation energy in the Al₂O₃ substrate was also calculated by

$$\Delta E(V_{O}) = E(Al_{2}O_{3})_{V_{O}} - E(Al_{2}O_{3})_{bulk} + \mu_{O}.$$
 (5)

Our experiments observed the Cu-Pd alloy and Cr oxide impurity phases on the composite sample of Al₂O₃, CuCrO₂, and PdCrO₂ (see § III A). The defect formation energies should be evaluated for the experimental conditions: the chemical equilibrium states consisting of Al₂O₃, CuCrO₂, PdCrO₂, Cu_xPd_{1-x}, and a chromium oxide. The exact value of x in Cu_xPd_{1-x} is not known experimentally. The ratio x potentially depends on the volume comparison of CuCrO₂ and PdCrO₂. However, the change in the results is negligible when x changes from 0.5 to 0.25 or 0.75 (variations of only 0.33 eV were observed), as described in the Supporting Information. Therefore, the results reported below assumed x = 0.5. Solving the following equations yields the chemical potentials. For example, if Al_2O_3 , $CuCrO_2$, $PdCrO_2$, CuPd, and Cr_3O_4 coexist, then

$$2\mu_{\rm A1} + 3\mu_{\rm O} = E({\rm Al}_2{\rm O}_3), \tag{6}$$

$$\mu_{\rm Cu} + \mu_{\rm Cr} + 2\mu_{\rm O} = E \,({\rm CuCrO}_2)\,,\tag{7}$$

$$\mu_{\rm Pd} + \mu_{\rm Cr} + 2\mu_{\rm O} = E \,({\rm PdCrO}_2)\,,\tag{8}$$

 $\mu_{\rm Cu} + \mu_{\rm Pd} = E \left({\rm CuPd} \right), \tag{9}$

$$3\mu_{\rm Cr} + 4\mu_{\rm O} = E \left({\rm Cr}_3 {\rm O}_4 \right). \tag{10}$$

There exist as many independent linear equations as unknown chemical potentials, so the chemical potentials are trivially determined.

C. Formation energies of defects as a function of the chemical potentials

The formation energies of point defects in Al₂O₃, CuCrO₂, and PdCrO₂ were calculated for different chromium oxides, as described in Section III B. We also considered the Cr metal as the Cr source of the Cr-rich limit. The results are summarized in Figure 2. The point-defect formation energies are all positive, so CuCrO₂ and PdCrO₂ are thermodynamically stable and stoichiometric under the considered chemical conditions. For low values of the oxygen chemical potential ($\leq -8.6 \text{ eV}$), the V₀ in CuCrO₂ and PdCrO₂ have the lowest formation energies; the V_0 in Al_2O_3 is much higher. As soon as the oxygen chemical potential increases, the V_{Cu} and V_{Pd} become the lowest formation energy defects. The Cr vacancies, by contrast, have much higher formation energies. The experimental chemical potentials are not well defined because the system is out of equilibrium, as described in Section IIIB. However, each element's stability corresponds to anywhere between the vertical lines that correspond to the oxygen chemical potentials with Cr_3O_4 and Cr_2O_3 . The V_{Cr} , Cu_{Cr}&V_{Cu}, and Pd_{Cr}&V_{Pd} are all Cr-deficient point defects. For CuCrO₂, the formation energy of $Cu_{Cr}\&V_{Cu}$ is lower than that of V_{Cr}. Therefore, the Cr site does not have a vacancy because a neighboring Cu occupies the Cr site by forming V_{Cu} next to Cu_{Cr}.

D. Instability of CuCrO₂ and PdCrO₂ for oxygen-deficient samples

Experiments found the segregation of impurity phases of Cu_xPd_{1-x} , Cr_2O_3 , and Cr_3O_4 on a 10 nm PdCrO₂ layer with a one-monolayer CuCrO₂ buffer layer on an Al₂O₃ substrate. The samples were grown under low oxygen partial pressures. The simultaneous presence of seven compunds (CuCrO₂, PdCrO₂, Cu_xPd_{1-x}, Cr₂O₃, Cr₃O₄, O₂, and Al₂O₃) but only five chemical elements complicates the theoretical analysis. Finding a solution for the chemical potential equations is impossible when the equations outnumber the independent variables. In this case, the system is out of equilibrium. The chemical potentials may not be uniform throughuot the sample. For instance, near the surface, the oxygen chemical potential may be a function of temperature and oxygen

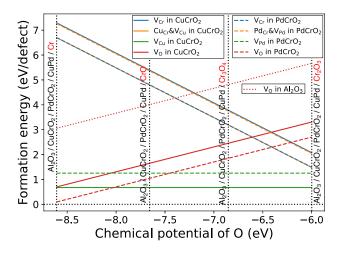


FIG. 2. Formation energies of intrinsic point defects in CuCrO₂, PdCrO₂, and Al₂O₃ calculated by the PBE+U method as a function of the oxygen chemical potential. The chemical potentials are calculated for CuCrO₂, PdCrO₂, Al₂O₃, CuPd, and different chromium oxides.

partial pressure. By contrast, near the regions where Cr_2O_3 and Cr_3O_4 coexist, the chemical potentials of Cr and O are uniquely determined by the formation energies of the two solids. Alternatively, near the Al_2O_3 substrate, the oxygen chemical potential may be determined by temperature and the concentration of oxygen vacancies in Al_2O_3 .

The impurity phases are oxygen deficient (i.e., chromium rich) relative to CuCrO₂ and PdCrO₂: the O/Cr ratios of Cr₂O₃ (1.5) and Cr₃O₄ (~1.3) are smaller than that of CuCrO₂ and PdCrO₂ (2.0). To elucidate the possible cause of impurity phase segregation, several different possible reactions originating from out-of-equilibrium states were considered. Then their potential to destabilize CuCrO₂ and PdCrO₂ was examined. The analysis revealed that low oxygen partial pressures and high temperatures could explain the segregation of Cr₂O₃ and Cu_xPd_{1-x}. Preexisting defects as energetic as oxygen vacancies in Al₂O₃ could enhance the segregation of Cr₃O₄ and Cu_xPd_{1-x}.

E. Thermochemical reactions

To simplify the analysis, the Cu_xPd_{1-x} alloy is assumed to be CuPd, as described in the last paragraph of Section III B. The theoretical approach shows that the combination of CuCrO₂ and PdCrO₂ is stable against the CrO₂ and CuPd impurity phase segregation, which is a stoichiometric process. The thermochemical equation of this segregation is

$$E(CuCrO_2) + E(PdCrO_2) = E(CuPd) + 2E(CrO_2) + Q(CrO_2),$$
(11)

where $Q(\text{CrO}_2)$ is the energy gained, or lost if negative, to form CrO_2 . The value of $Q(\text{CrO}_2)$ was calculated to be

-1.102 eV per two formula units of CrO₂, so this reaction is endothermic.

By contrast, the Cr/O ratios of CuCrO₂ and PdCrO₂ vs. Cr₂O₃ or Cr₃O₄ are different. Therefore, the impurity phase segregation may be caused by an impurity-absorbing defect. For Cr₂O₃+CuPd, the impurity phase segregation may be caused and promoted by an oxygen-adsorbent mechanism because the Cr/O ratios of CuCrO₂ and PdCrO₂ (1/2) and Cr₂O₃ (2/3) are different. This oxygen deficiency may be the result of low environmental oxygen concentration relative to chromium from either (i) defective CuCrO₂, PdCrO₂, or Al₂O₃ or (ii) low oxygen content in the vacuum growth chamber [42]. For mechanism (i), preexisting V₀ in CuCrO₂, PdCrO₂, or Al₂O₃ and formation of Cr-deficient defects such as V_{Cr} in CuCrO₂ or PdCrO₂ were considered to keep the Cr/O ratios constant before and after the process [43].

Therefore, the energy gain obtained by the (dis)appearance of point defects in $CuCrO_2$, $PdCrO_2$, and Al_2O_3 was compared with the release of oxygen molecules into the oxygen gas in the growth chamber. All these possibilities were considered as particle exchanges with a particle bath.

The energy cost of taking an atom ($\alpha = 0$ or Cr) from one of these particle baths is defined as

$$v_{\alpha} \equiv E(\text{bath})_{\text{bulk}} - E(\text{bath})_{\alpha}.$$
 (12)

Here, $E(\text{bath})_{\text{bulk}}$ and $E(\text{bath})_{\alpha}$ are the energies of the particle bath without defects and with an $\alpha = 0$ or Cr vacancy, respectively [44].

The thermochemical equations for the segregation of Cr_2O_3 when introducing O to or removing Cr from the particle bath are given as follows:

$$E(\operatorname{CuCrO}_2) + E(\operatorname{PdCrO}_2) = E(\operatorname{CuPd}) + E(\operatorname{Cr}_2\operatorname{O}_3) + \nu_{\mathrm{O}} + Q\left(\operatorname{Cr}_2\operatorname{O}_3, \operatorname{V}_{\mathrm{O}}^{\mathrm{rem}}\right),$$
(13)

$$E(\text{CuCrO}_2) + E(\text{PdCrO}_2) = E(\text{CuPd}) + (4/3)E(\text{Cr}_2\text{O}_3) - (2/3)v_{\text{Cr}} + Q(\text{Cr}_2\text{O}_3, \text{V}_{\text{Cr}}^{\text{int}}).$$
(14)

In equation (13), the term v_0 takes into account the effect of removing an oxygen vacancy in the particle bath, and $-(2/3)v_{Cr}$ considers the effect of creating a fraction of Cr vacancies in the particle bath.

Similarly, the segregation of Cr_3O_4 could be explained by the following reactions:

$$E(\text{CuCrO}_{2}) + E(\text{PdCrO}_{2}) = E(\text{CuPd}) + (2/3)E(\text{Cr}_{3}\text{O}_{4}) + (4/3)\nu_{O} + Q(\text{Cr}_{3}\text{O}_{4}, \text{V}_{O}^{\text{rem}}), \quad (15)$$

$$E(\operatorname{CuCrO}_2) + E(\operatorname{PdCrO}_2) = E(\operatorname{CuPd}) + E(\operatorname{Cr}_3\operatorname{O}_4) - \nu_{\operatorname{Cr}} + Q\left(\operatorname{Cr}_3\operatorname{O}_4, \operatorname{V}_{\operatorname{Cr}}^{\operatorname{int}}\right).$$
(16)

Their derivations are described in detail in Appendix A.

The exothermic energies, Q, are shown in eqs (13)–(16), for different values of v_0 and v_{Cr} , depending on the particle baths

in Table I. The table shows that only $Q(Cr_2O_3, V_O^{rem})$ and $Q(Cr_3O_4, V_O^{rem})$ can be positive (i.e., exothermic reaction), whereas the reactions involving the formation of Cr-deficient defects are always endothermic. Therefore, the preexisting oxygen vacancies could explain the spontaneous segregation of Cr₂O₃, Cr₃O₄, and CuPd impurity phases.

Figure 3 shows $Q(Cr_2O_3, V_O^{rem})$ and $Q(Cr_3O_4, V_O^{rem})$ in Table I for different v_0 (i.e., different particle bath). The stability of oxygen atoms in each particle bath negatively correlates with v_0 : oxygen atoms are the most (least) stable in Al₂O₃ (O₂ gas). $Q(Cr_2O_3, V_O^{rem})$ changes depending on $-v_0$, as given in eq (13). Similarly, $Q(Cr_3O_4, V_O^{rem})$ changes depending on $-(4/3)v_0$, as given in eq (15). The impurity phase segregation is endothermic when O₂ gas is the particle bath and exothermic for the other particle baths. The energetically favored chromium oxide changes from Cr_2O_3 to Cr_3O_4 with v_0 decreasing from PdCrO₂ to Al₂O₃.

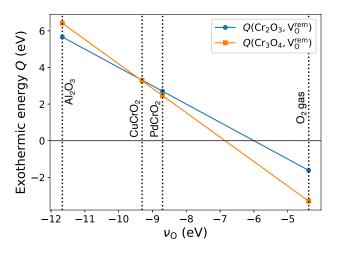


FIG. 3. Plots of $Q(Cr_2O_3, V_O^{rem})$ and $Q(Cr_3O_4, V_O^{rem})$ shown in Table I for different v_0 (i.e., different O particle baths).

F. Entropy contributions to the formation of Cr_2O_3 and Cr_3O_4

In this section, entropy contributions to the positive $Q(Cr_2O_3, V_O^{rem})$ and $Q(Cr_3O_4, V_O^{rem})$ are considered. For convenience, $Q(Cr_2O_3) \equiv Q(Cr_2O_3, V_O^{rem})$ and $Q(Cr_3O_4) \equiv Q(Cr_3O_4, V_O^{rem})$.

Entropy contributions depend on the temperature, pointdefect densities, and oxygen partial pressure. The energies E were replaced by Helmholtz free energies F(T) in eqs (13) and (15). For bulk structures, F(T) was evaluated by

$$F(T) = E + F_{\rm vib}(T). \tag{17}$$

Here, $F_{vib}(T)$ is the vibrational free energy. For v_0 in a defective solid, the vacancy configurational entropy contribution

was considered in addition to $F_{vib}(T)$. If the vacancy density is c_v , then the free energy change when removing one vacancy is

$$\Delta F_{\text{config}}(T, c_{v}) = k_{\text{B}}T[-\ln(c_{v}) + \ln(1 - c_{v})]$$
(18)

(details in Appendix B). Here, $k_{\rm B}$ is the Boltzmann constant. Therefore, $Q({\rm Cr}_2{\rm O}_3)$ and $Q({\rm Cr}_3{\rm O}_4)$ depend on vacancy density and temperature when the bath location is a defective solid.

When considering the case of O_2 released into the growth chamber, because the experimental oxygen partial pressure is very low and the temperature is high, the translational entropy contribution could significantly stabilize the oxygen gas. This stabilization may change $Q(Cr_2O_3)$ and $Q(Cr_3O_4)$ from negative to positive. Without entropy contributions, they are negative, as shown in Table I. The Helmholtz free energy F(T) of the oxygen gas per molecule is defined as

$$F(T, P_{O_2}) = E(O_2) + F_{vib}(T) + F_{rot}(T) + F_{trans}(T, P_{O_2})(19)$$

Here, $E(O_2)$ is the energy of an isolated oxygen molecule and $F_{vib}(T)$, $F_{rot}(T)$, and $F_{trans}(T, P_{O_2})$ are free energies by vibrational, rotational, and translational entropies, respectively. Then $F_{rot}(T)$ and $F_{trans}(T, P_{O_2})$ [45] are given by

$$F_{\rm rot}(T) = -k_{\rm B}T \left(1 + \ln \frac{8\pi^2 I k_{\rm B} T}{2h^2}\right),$$
 (20)

$$F_{\text{trans}}(T, P_{O_2}) = -k_{\text{B}}T \ln \frac{k_{\text{B}}T}{P_{O_2}\Lambda^3},$$
 (21)

$$\Lambda \equiv \frac{h}{\sqrt{2\pi m k_{\rm B} T}} \tag{22}$$

Here, *h* is the Planck constant, and *I* is the moment of inertia of an oxygen molecule. Therefore, $Q(Cr_2O_3)$ and $Q(Cr_3O_4)$ depend on oxygen partial pressure and temperature when the bath location is the dilute oxygen gas.

The entropy contributions in eqs (13) and (15) yield $Q(Cr_2O_3)$ and $Q(Cr_3O_4)$ for different bath locations and conditions. In these equations, the bulk free energies depend on only the temperature. When the bath is a defected crystal, v_0 depends on temperature and vacancy density. When the bath is the oxygen gas, v_0 depends on temperature and oxygen partial pressure. When v_0 's entropy contributions are ignored, $Q(Cr_2O_3)$ and $Q(Cr_3O_4)$ barely depend on the temperature: $Q(Cr_2O_3)$ and $Q(Cr_3O_4)$ do not change more than 60 meV from 600 to 1000 K, and $Q(Cr_2O_3) - Q(Cr_3O_4)$ does not change more than 11 meV from 600 to 1000 K. Therefore, the dependence of $Q(Cr_2O_3)$ and $Q(Cr_3O_4)$ on the conditions is almost equivalent to that of v_0 .

To understand the conditions under which different oxides might be generated experimentally, different baths for exchanging oxygen were systematically considered. When the bath is a defected crystal, v_0 was calculated for vacancy densities in the range of 10^{-8} – 10^{-1} per site and temperatures in the range of 600–1000 K. When the bath is the oxygen gas, v_0 was calculated for oxygen partial pressures in the range of 10^{-6} – 10^0 atm and temperatures in the range of 600–1000 K.

TABLE I. Exothermic energies, Q in eqs (13)–(16), for the formation of Cr_2O_3 or Cr_3O_4 and CuPd accompanied by V_O^{rem} 's removal from or V_{Cr}^{int} 's introduction to different bath locations.

Bath location	$Q(Cr_2O_3, V_0^{rem})$	$Q(Cr_2O_3, V_{Cr}^{int})$	$Q(Cr_3O_4, V_0^{rem})$	$Q(Cr_3O_4, V_{Cr}^{int})$
PdCrO ₂	+2.703	-0.990	+2.466	-3.192
CuCrO ₂	+3.308	-0.989	+3.273	-3.189
Al ₂ O ₃	+5.666	_	+6.417	-
O_2 in vacuum ($T = 0$)	-1.619	_	-3.297	-

Figure 4 shows a map of the v_0 calculated for different bath locations. The vertical width of each area indicates the variation width corresponding to vacancy densities in the range of $10^{-8}-10^{-1}$ per site or oxygen partial pressures in the range of $10^{-6}-10^0$ atm. Figure 4 is divided into the three regions I–III according to the corresponding $Q(Cr_2O_3)$ and $Q(Cr_3O_4)$ values. The region I is $Q(Cr_2O_3, Cr_3O_4) < 0$: the impurity phase segregation does not proceed spontaneously. The region II is $Q(Cr_2O_3) > 0$ and $Q(Cr_2O_3) > Q(Cr_3O_4)$: $Cr_2O_3 + Cu_xPd_{1-x}$ is spontaneously predominantly formed. The region III is $Q(Cr_3O_4) > Q(Cr_2O_3) > 0$: $Cr_3O_4 + Cu_xPd_{1-x}$ is spontaneously predominantly formed. Therefore, when the particle bath is oxygen gas, $CuCrO_2$, or $PdCrO_2$, the majority of chromium oxide is Cr_2O_3 . When the particle bath is Al_2O_3 , the majority of chromium oxide is Cr_3O_4 .

Furthermore, other bath locations than the above listed are realistically possible. For example, an oxygen-terminated PdCrO₂ surface could lead to very high v_0 . By contrast, a Pd-terminated surface could lead to very low v_0 . Investigation of such further complicated mechanisms is a possible future work for theory and experiments.

These calculations revealed that v_0 in O_2 gas decreases with decreasing oxygen partial pressure, and v_0 in defected crystals decreases with increasing c_v (details in supporting information). This result is not surprising because it indicates that gaseous oxygen molecules are more stable under oxygenpoor conditions. In reality, c_v would negatively correlates with oxygen partial pressure, so v_0 positively correlates with oxygen partial pressure in every bath location: lower oxygen partial pressure facilitates the segregation of impurity phases. This analysis agrees with the experimental finding described in Section III A: Cr₂O₃ formation negatively correlates with oxygen partial pressure.

However, this analysis does not explain the independence of Cr_3O_4 formation on oxygen partial pressure. Rather, Cr_3O_4 formation strongly depends on temperature, unlike Cr_2O_3 . Some hypotheses are considered to explain the Cr_3O_4 experimental results. (i) Most of the bath locations belong to region II in Figure 4, and the temperature determines how much the metastable Cr_3O_4 is segregated. (ii) Some of the bath locations belong to region III, but high barrier energy is required to transfer oxygen atoms, moving oxygen vacancies, so the temperature determines the oxygen exchange rate.

For example, the barrier energy required to transfer oxygen atoms from Al_2O_3 to the surface would be higher than from PdCrO₂ to the surface. To verify the hypotheses, saddle state analyses by methods such as the nudged elastic band method, molecular dynamics, and/or modeling the sample's surface should be applied in future works.

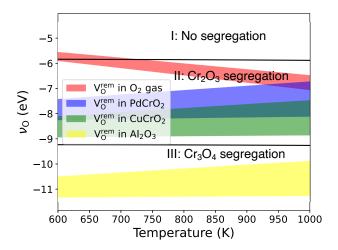


FIG. 4. Plots of the energy of the oxygen sink (v_0) using eq (12) for different possible locations in the experimental range of temperatures and estimated concentration. The upper and lower edges of V_0^{rem} in O_2 gas are $P_{O_2} = 1$ and 10^{-6} atm. The upper and lower edges of the other areas are $c_v = 10^{-1}$ and 10^{-8} per site. The dark green area between the blue and green areas is the overlap of the blue and green areas.

IV. CONCLUSION

The mechanism of impurity phase segregation with the epitaxial growth of a PdCrO₂ layer on a CuCrO₂ buffer layer on an Al₂O₃ substrate was investigated via a combination of experiments and ab initio calculations. XRD experiments revealed the formation of Cu_xPd_{1-x} alloy and chromium oxide (Cr₂O₃ and Cr₃O₄) impurity phases. Consequently, the impurity phase segregation should be involved with appearance or disappearance of point defects or oxygen migration because the possible segregation processes are not stoichiometric. In this scenario, several possible mechanisms of impurity phase segregation were considered with oxygen vacancy disappearance or chromium vacancy appearance into different particle baths: Al₂O₃, CuCrO₂, PdCrO₂, and the dilute oxygen gas. Calculations established that the oxygen vacancy consumption processes are energetically favorable and supported experimental evidence that Cr_2O_3 or Cr_3O_4 are the predominant chromium oxide impurity phases. Specifically, preventing the release of oxygen atoms from delafossite materials could suppress the impurity phase segregation.

APPENDIX

A. Derivation of eqs (13) and (14)

For ease of explanation, let the particle bath be $PdCrO_2$. Consider the following thermochemical equations for the segregation of Cr_2O_3 by removing preexisting O vacancies or creating Cr vacancies.

$$E(CuCrO_{2})_{bulk}^{(n)} + E(PdCrO_{2})_{V_{O}}^{(n)}$$

= $E(CuCrO_{2})_{bulk}^{(n-1)} + E(PdCrO_{2})_{bulk}^{(n-1)}$
+ $E(CuPd) + E(Cr_{2}O_{3}) + Q(Cr_{2}O_{3}, V_{O}^{rem})$ (23)

and

$$E(CuCrO_{2})_{bulk}^{(n)} + E(PdCrO_{2})_{bulk}^{(n)}$$

= $E(CuCrO_{2})_{bulk}^{(n-1)} + E(PdCrO_{2})_{(2/3)V_{Cr}}^{(n-1)}$
+ $E(CuPd) + (4/3)E(Cr_{2}O_{3}) + Q(Cr_{2}O_{3}, V_{Cr}^{int}).$ (24)

Here, for example, $E(\text{CuCrO}_2)_{\text{bulk}}^{(n)}$ is the energy of *n* f.u. bulk CuCrO₂, $E(\text{PdCrO}_2)_{V_0}^{(n)}$ is the energy of *n* f.u. PdCrO₂ with an oxygen vacancy, $E(\text{PdCrO}_2)_{(2/3)V_{\text{Cr}}}^{(n-1)}$ is the energy of (n-1)f.u. PdCrO₂ with a fraction of 2/3 chromium vacancies, and E(CuPd) is the energy of 1 f.u. bulk CuPd. For the bulk, the following relationships hold according to the definitions.

$$E(\operatorname{CuCrO}_2)_{\text{bulk}}^{(n)} = n E(\operatorname{CuCrO}_2), \qquad (25)$$

$$E(PdCrO_2)_{bulk}^{(n)} = n E(PdCrO_2).$$
 (26)

Define the energy gain from removing m oxygen or chromium vacancies in nPdCrO₂ as follows:

$$\nu_{\rm O}(n,m) \equiv E({\rm PdCrO_2})^{(n)}_{\rm bulk} - E({\rm PdCrO_2})^{(n)}_{m{\rm V_O}},\qquad(27)$$

$$\nu_{\rm Cr}(n,m) \equiv E({\rm PdCrO}_2)^{(n)}_{\rm bulk} - E({\rm PdCrO}_2)^{(n)}_{m\,{\rm V}_{\rm Cr}}.$$
 (28)

In the thermodynamic limit $(n \to \infty)$, the following relationships should hold:

$$\nu_{\mathrm{O,Cr}}(n,m) \simeq \nu_{\mathrm{O,Cr}}(n-1,m), \tag{29}$$

$$\nu_{\text{O,Cr}}(n,m) \simeq m \, \nu_{\text{O,Cr}}(n,1), \tag{30}$$

Moreover, define

$$\nu_{\rm O,Cr} \equiv \nu_{\rm O,Cr}(n,1) \tag{31}$$

These are the v_{α} defined in eq (12). Applying eqs (25)–(31) to eqs (23) and (24), yields eqs (13) and (14).

B. Configurational entropy of removing a vacancy.

When n vacancies exist in N sites, the configurational entropy is

$$S(N,n) = k_{\rm B} \ln \frac{N!}{(N-n)!n!}.$$
 (32)

The entropy change achieved by adding one vacancy is given by

$$\Delta S(N,n) \equiv S(N,n+1) - S(N,n)$$

= $k_{\rm B} \left[-\ln (c_{\rm v} + 1/N) + \ln (1 - c_{\rm v}) \right],$ (33)
 $c_{\rm v} \equiv n/N.$ (34)

For the limit of $N \to \infty$ with fixed c_{ν} ,

$$\Delta S(N,n) \to \Delta S(c_v) = k_{\rm B} \left[-\ln(c_v) + \ln(1-c_v) \right] \quad (35)$$

Therefore, the free energy change achieved by removing one vacancy is given by

$$\Delta F(T, c_v) = -T(-S(c_v)) \tag{36}$$

$$= k_{\rm B}T \left[-\ln \left(c_{\rm v} \right) + \ln \left(1 - c_{\rm v} \right) \right]. \tag{37}$$

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$$r = \frac{\sigma_{X,Y}}{\sigma_X \sigma_Y}.$$
 (38)

Here, σ_X and σ_Y are the standard deviations of $\{X_i\}_{i=1}^n$ and $\{X_i\}_{i=1}^n$. $\sigma_{X,Y}$ is the covariance of the two data-series:

$$\sigma_{XY} = \frac{1}{n} \sum_{i=1}^{n} (X_i - \bar{X})(Y_i - \bar{Y}).$$
(39)

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